

Laser, X-Ray, and Ion Heating of Reflective & Transmissive Final Optics



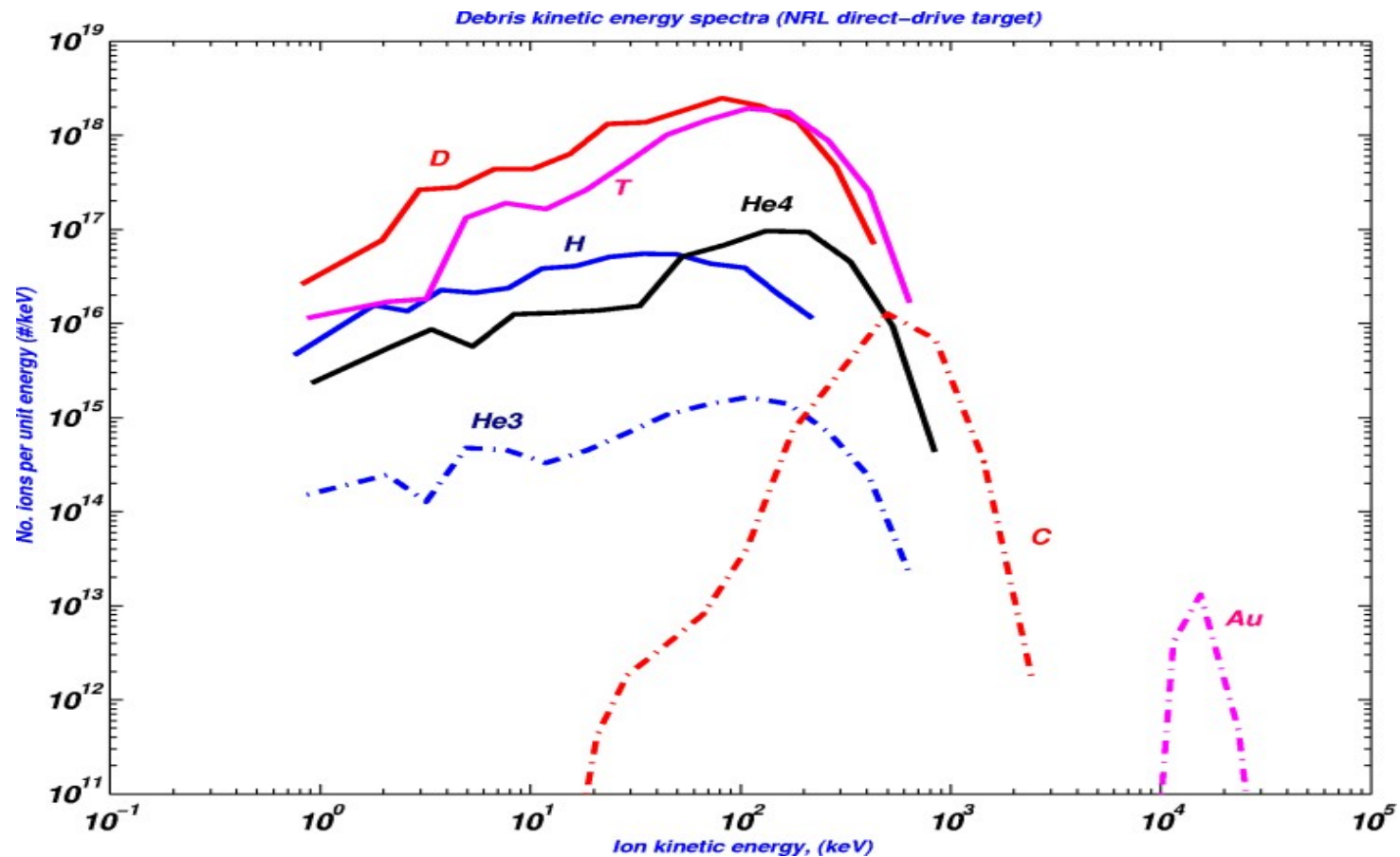
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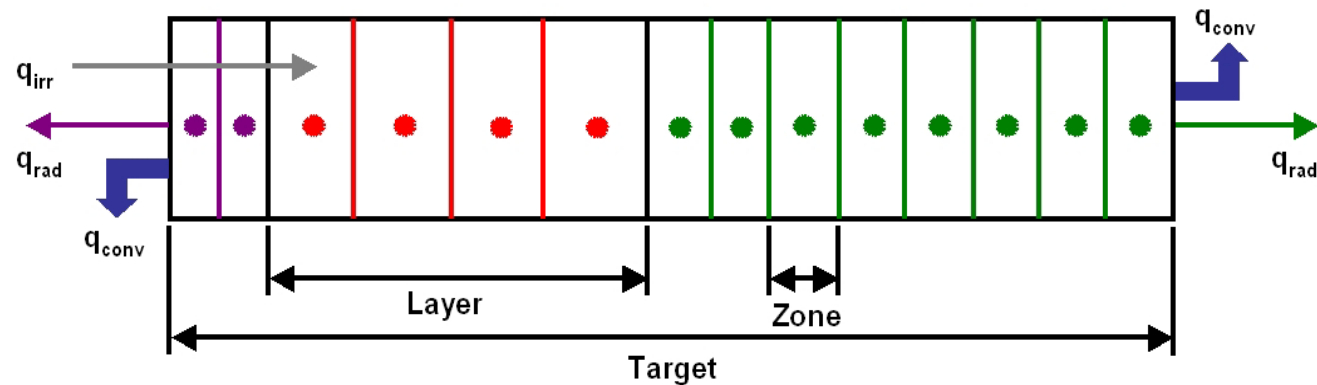
Laser profile and target spectra are the first ingredients in determining final optic temperature and stress conditions



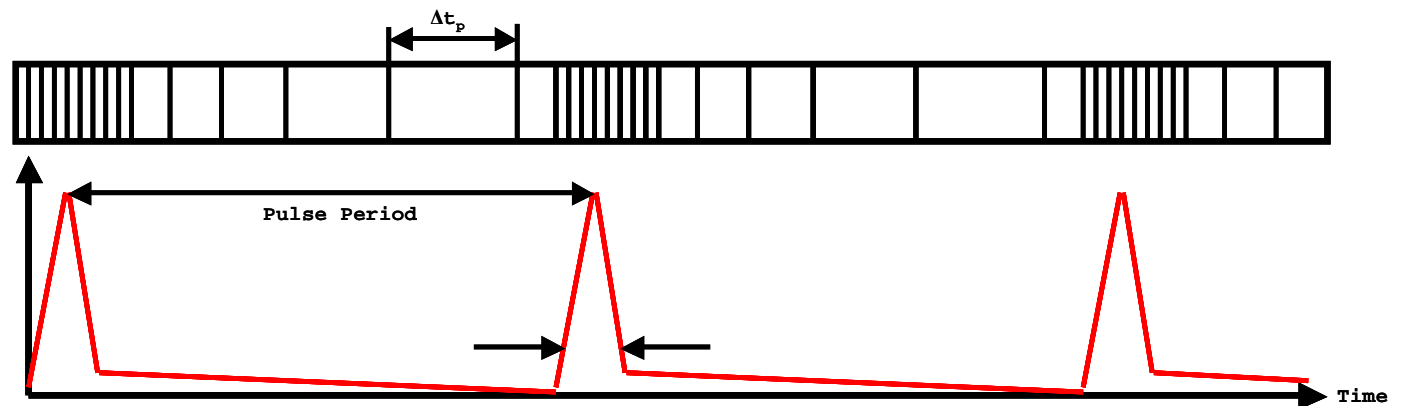
- With consideration of system geometry, the raw target output spectra for x-rays and burn & debris ions can be translated into inputs for RadHeat



RadHeat is a transient heat transfer code that can handle multilayer targets in pulsed radiation environments...



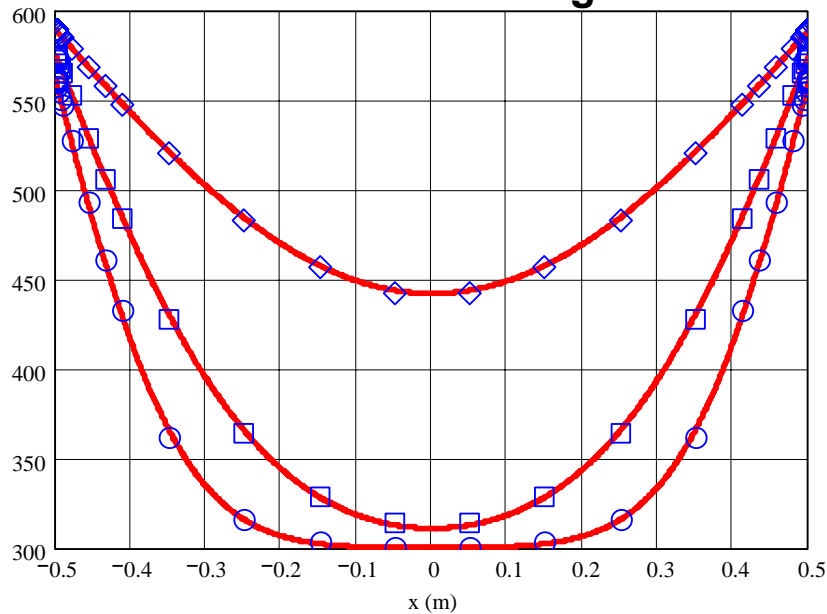
- Robust implicit time-stepping, temperature dependent material properties, flexible meshing and a host of other features make RadHeat an ideal tool for studying transient thermal processes in IFE chamber component studies



... that has been benchmarked with good success



- Response of flat plate to symmetric convective surface heating**



- Theory 100s
- Theory 250s
- Theory 1000s
- RadHeat 100s
- RadHeat 250s
- ◇ RadHeat 1000s

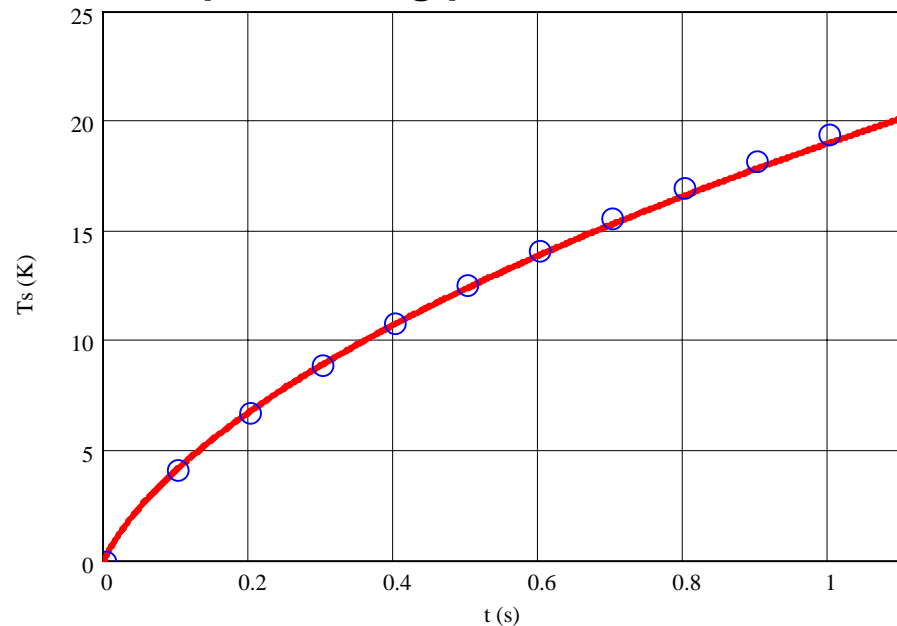
$$T_s = \frac{q}{k \cdot \gamma} \cdot \left(\frac{2 \cdot \zeta}{\sqrt{\pi}} - 1 + e^{\zeta^2} \cdot \text{erfc}(\zeta) \right)$$

$$\zeta = \gamma \cdot \sqrt{\alpha \cdot t} \quad \alpha = \frac{k}{\rho \cdot c}$$

$$T = (T_i - T_f) \cdot \left[\sum_{n=1}^{\infty} \left[C_n e^{-\frac{(\zeta_n)^2 \cdot \alpha \cdot t}{L^2}} \cdot \cos\left(\frac{x}{L} \cdot \zeta_n\right) \right] \right] + T_f$$

$$C_n = \frac{4 \cdot \sin(\zeta_n)}{2 \cdot \zeta_n + \sin(2 \cdot \zeta_n)}$$

- Response of semi-infinite wall to heating from penetrating photon irradiation**



- Theory
- RadHeat

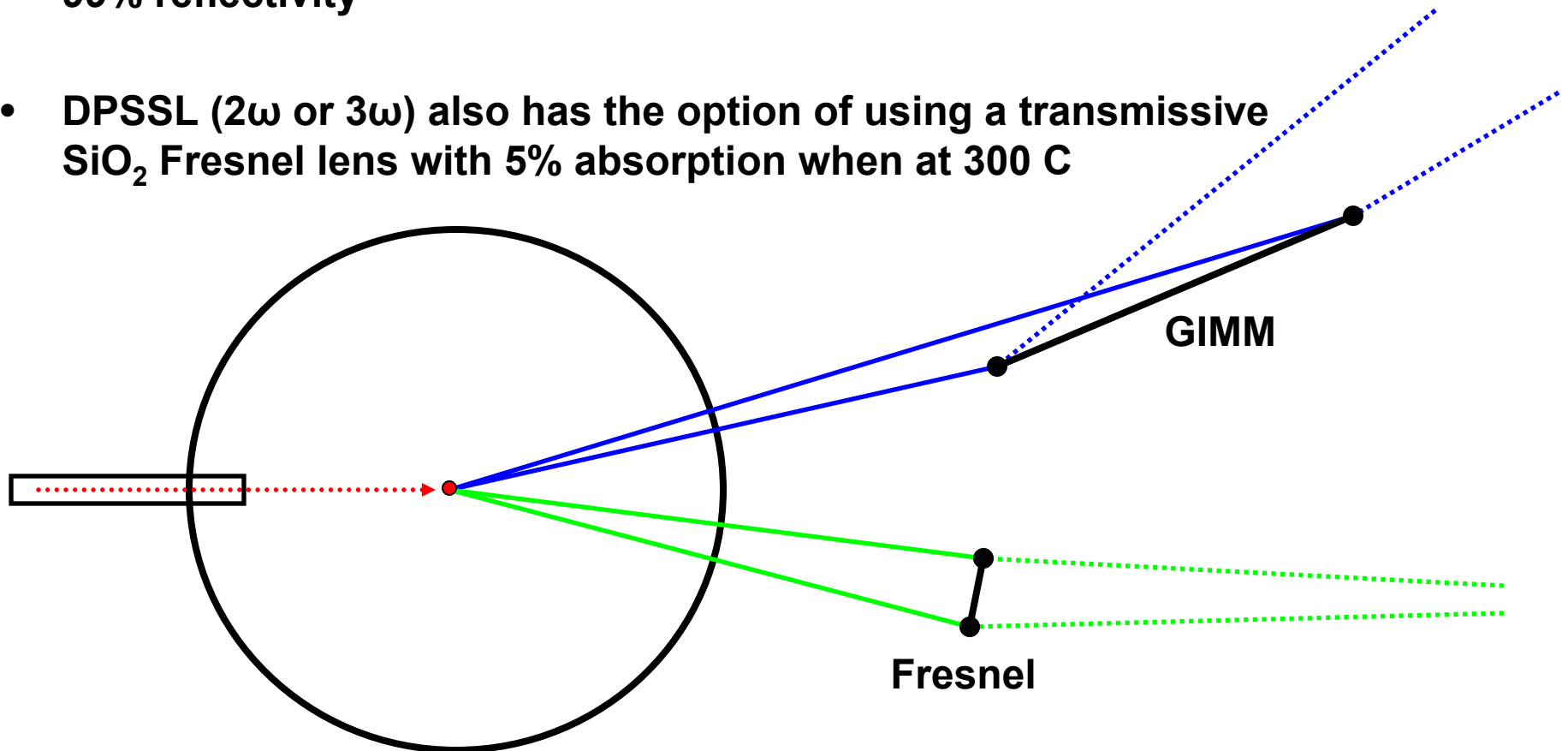
Physics & Advanced Technologies



Both reflective and transmissive candidates are being considered for IFE final optics



- The base-case KrF (4ω) final optic is a grazing incidence metal mirror (GIMM) made from aluminum and oriented 85° to achieve 99% reflectivity
- DPSSL (2ω or 3ω) also has the option of using a transmissive SiO_2 Fresnel lens with 5% absorption when at 300 C



Fluence limitations on both approaches must be put in the proper context



	GIMM @ 85°	Fresnel
Normal to beam laser fluence goal	5.0e+00 J/cm²	2.0e+00 J/cm²
Corresponding optic normal fluence	4.4e-01 J/cm²	2.0e+00 J/cm²
Normal to beam fluence absorbed	4.4e-03 J/cm²	1.0e-01 J/cm²
Specific heating to optic	2.9e+01 J/g	8.7e-01 J/g



We simulated several optic configurations using RadHeat



- **A reflective Al GIMM at 26 m from chamber center subjected to a KrF laser pulse and output from a 350 MJ target at 85°**
- **A transmissive SiO₂ Fresnel lens also at 26 m subjected to a DPSSL laser pulse and the same target output used for the GIMM**
- **A Fresnel lens identical to the situation above but without ion irradiation**

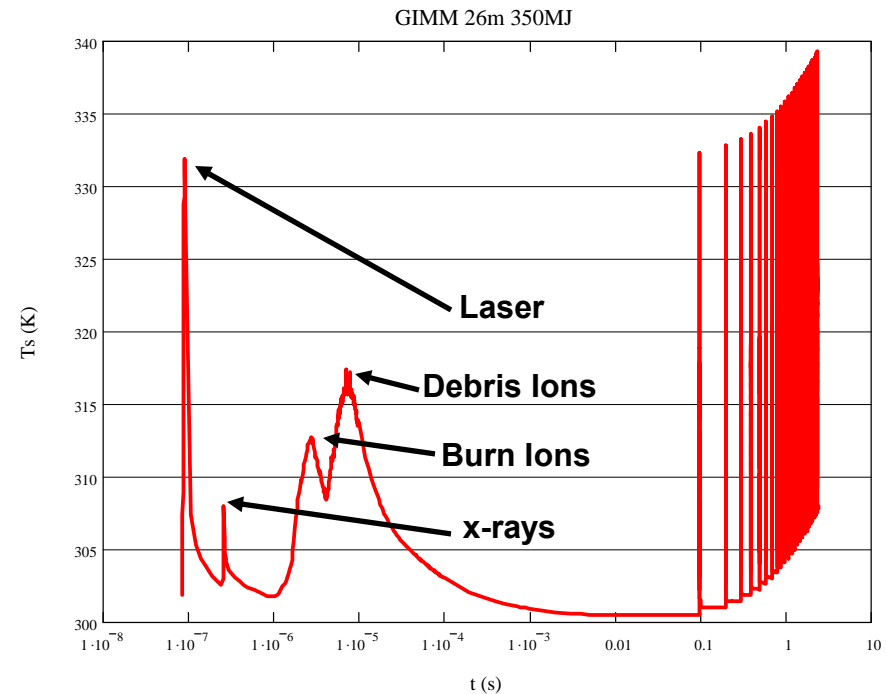
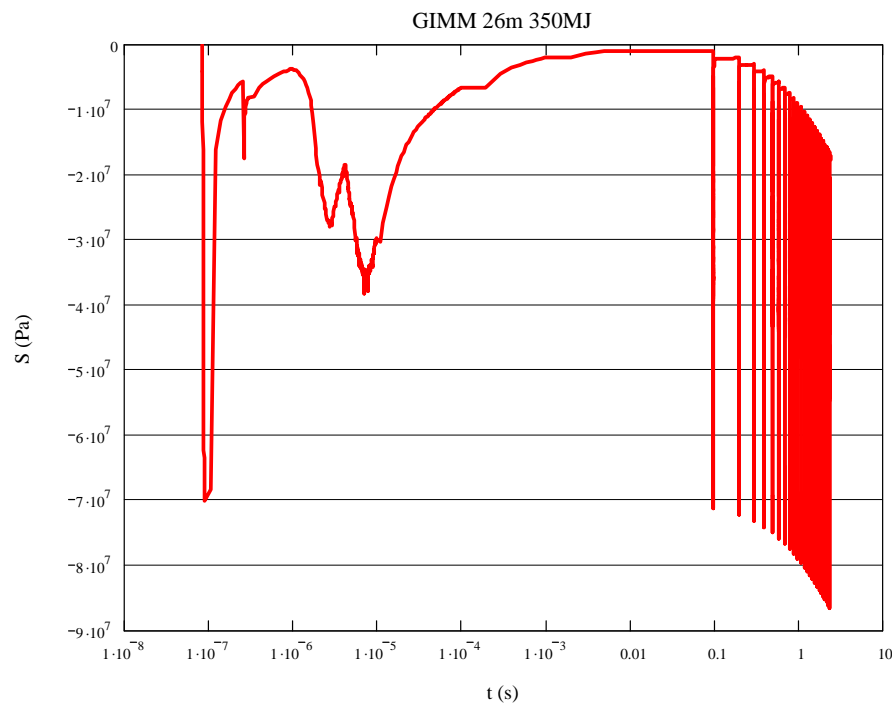
The final case indicates what would happen if a successful ion deflection scheme were employed



The GIMM run shows that while the temperature response may seem reasonable, stresses will could be significant



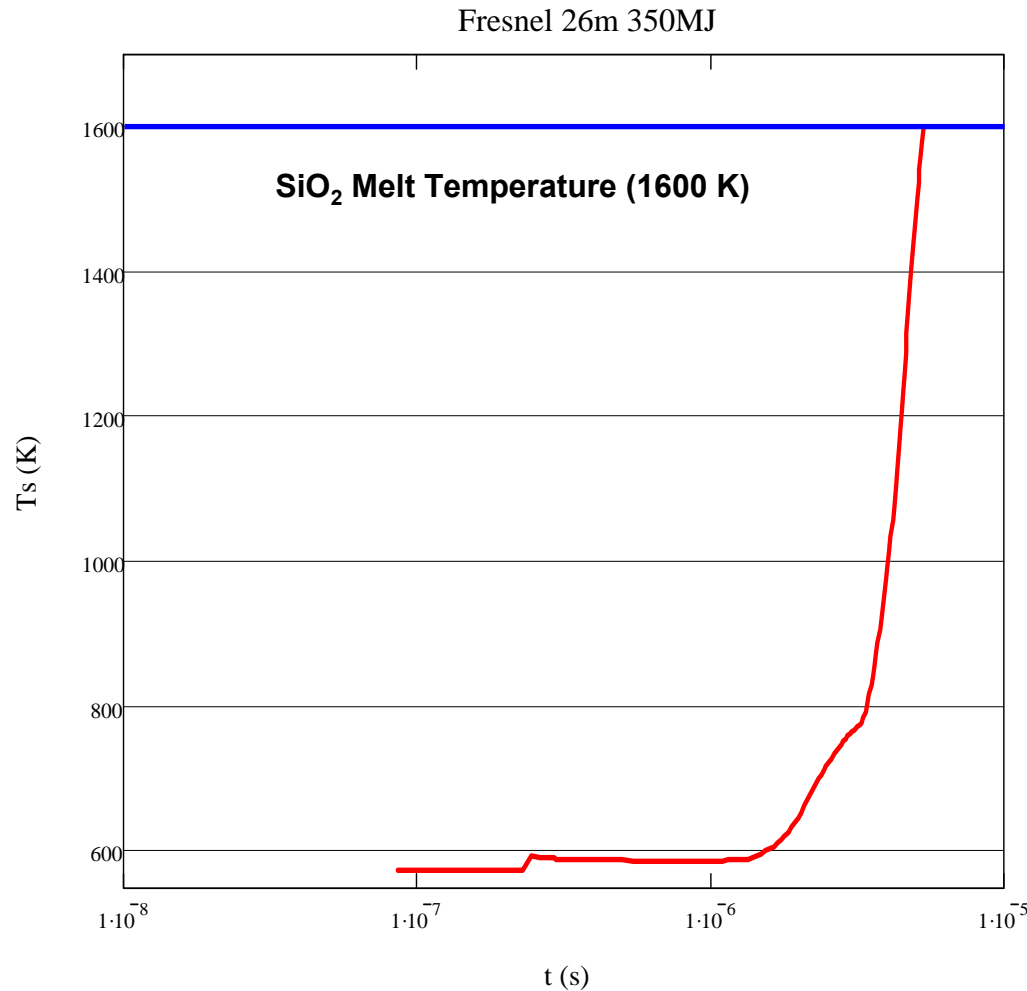
- **The laser pulse will generate the greatest temperature spike with a magnitude of ~ 30 degrees**



- **Compressive surface stresses could cause the optic to yield in compression and pose a fatigue or cracking threat**



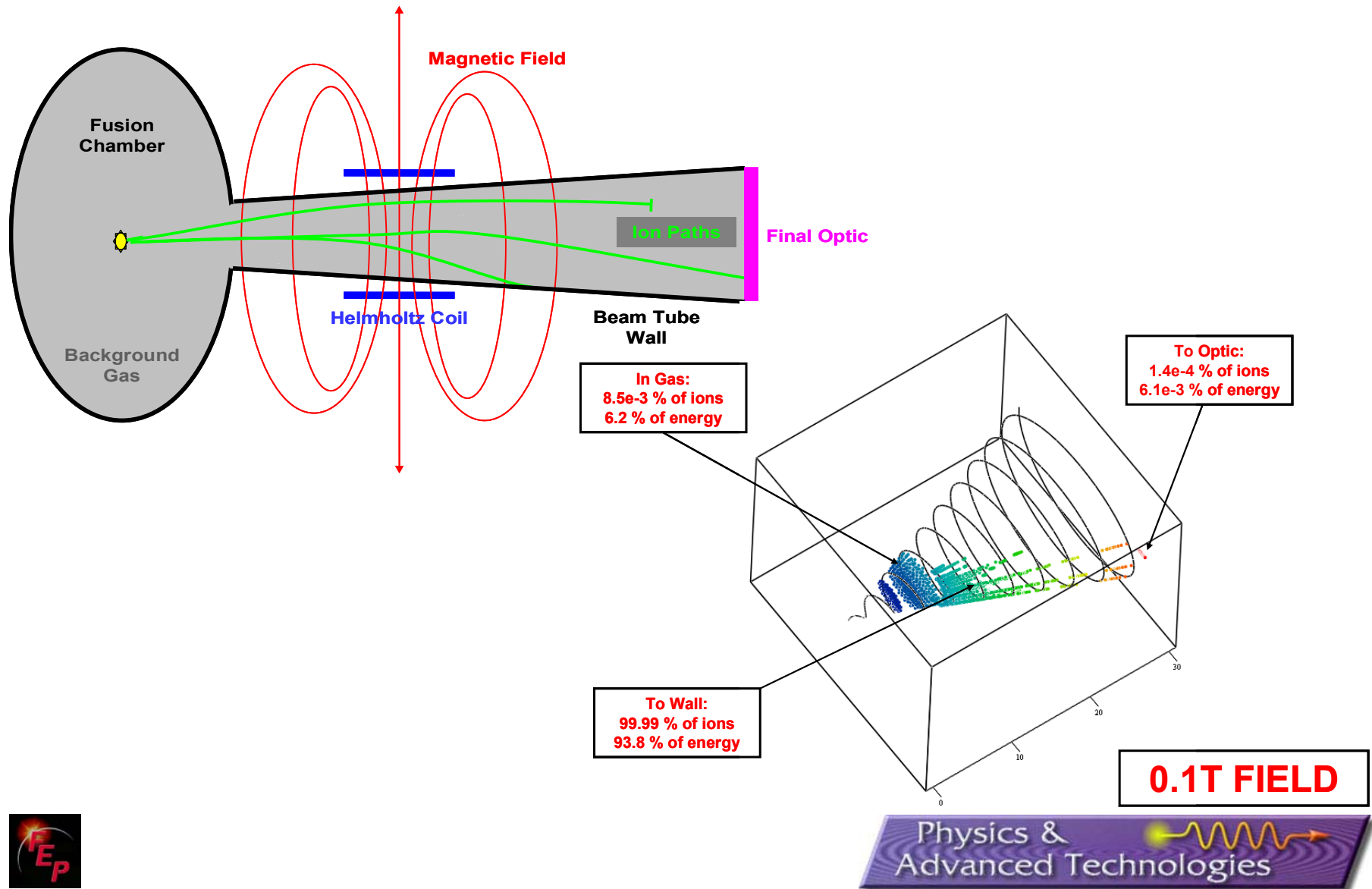
The Fresnel run indicates ion irradiation will cause the silica to melt



- **Laser has virtually no heating effect on transmissive optic due to the volumetric nature of energy deposition**
- **Reduced thermal conductivity bottles ion energy in thin deposition layer leading to surface melting**



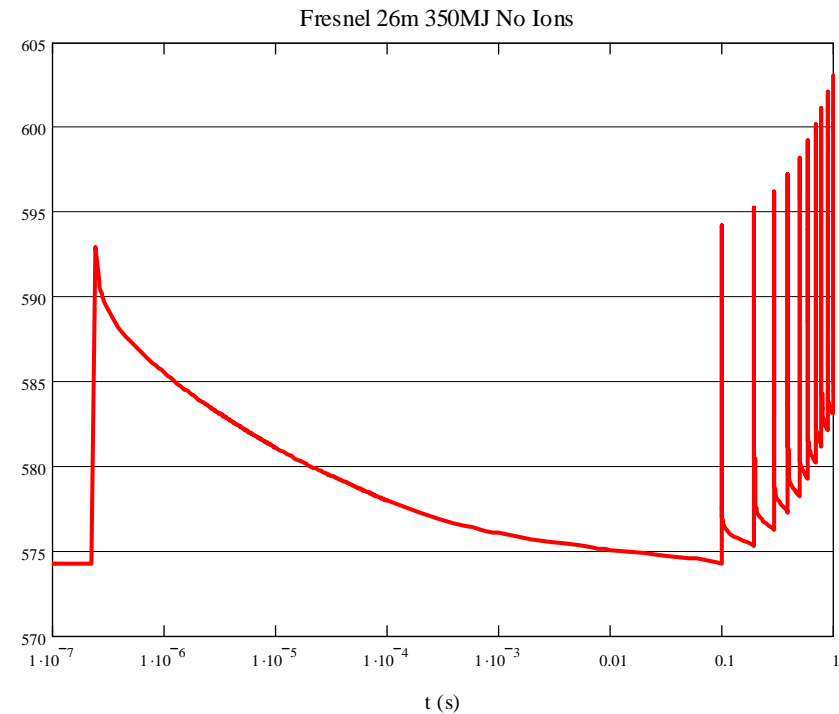
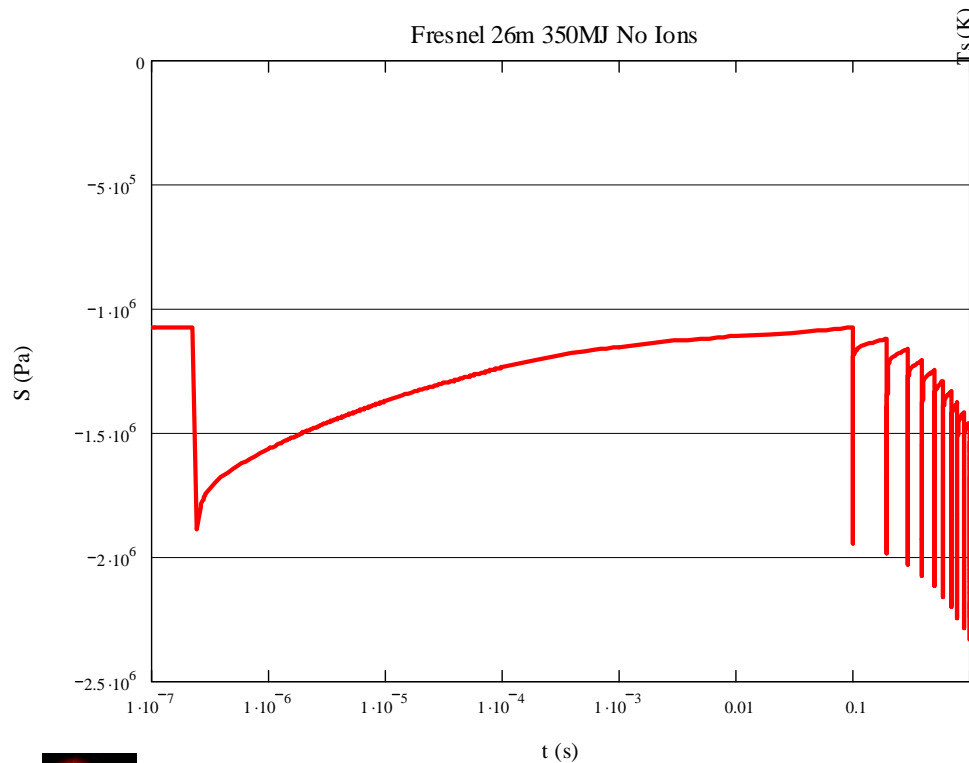
Ion deflection will therefore be needed for Fresnel optics



With ion deflection, surface temperatures of silica are much more reasonable



- **Without ion irradiation, the Fresnel lens will experience temperature spikes from x-rays similar to those the GIMM sees**



- **The low thermal expansion of silica makes it exceptionally resistant to thermal shock from the x-rays**

